Electronic Acknowledgement Receipt					
EFS ID:	1196349				
Application Number:	09941827				
Confirmation Number:	7551				
Title of Invention:	METHOD OF IMPROVED HIGH K DIELECTRIC-POLYSILICON INTERFACE FOR CMOS DEVICES				
First Named Inventor:	Ronald A. Weimer				
Customer Number:	31870				
Filer:	Thomas Pienkos/Jere Polmatier				
Filer Authorized By:	Thomas Pienkos				
Attorney Docket Number:	MTI-31532				
Receipt Date:	12-SEP-2006				
Filing Date:	29-AUG-2001				
Time Stamp:	12:49:24				
Application Type:	Utility				
International Application Number:					
Dovment information.					

Payment information:

Submitted with Payment	no
------------------------	----

File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part	Pages
1		MTl31532.pdf	987256	yes	32

	Multipart Description			
	Doc Desc	Start	End	
	Amendment after Notice of Allowance (Rule 312)	1	1	
	Claims	2	31	
	Applicant Arguments/Remarks Made in an Amendment	32	32	
Warnings:				

Information:

Total Files Size (in bytes): 987256

This Acknowledgement Receipt evidences receipt on the noted date by the USPTO of the indicated documents, characterized by the applicant, and including page counts, where applicable. It serves as evidence of receipt similar to a Post Card, as described in MPEP 503.

New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.